

## Electronic Supplementary Information

### **Heterostructure made from Bone-like Plasmonic Au Nanoantennas and ZnO Quantum Dots for Broadband Photodetectors**

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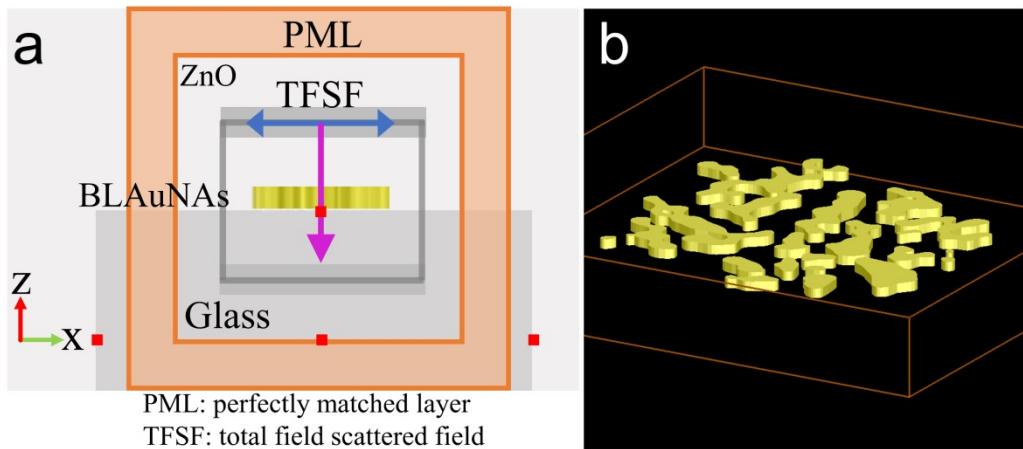
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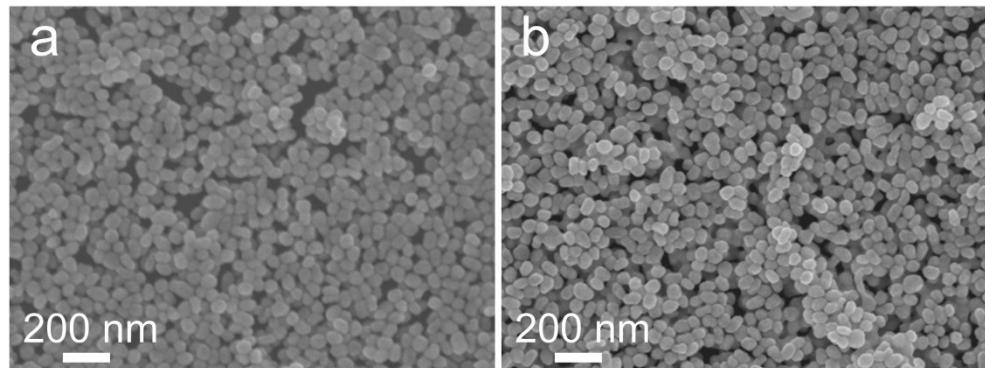
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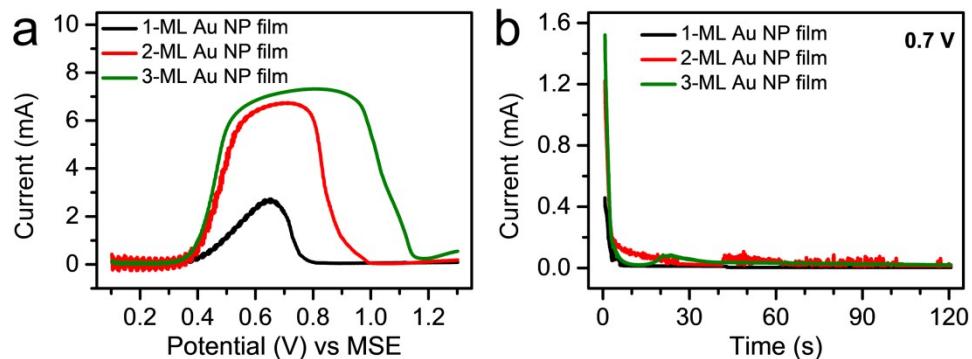
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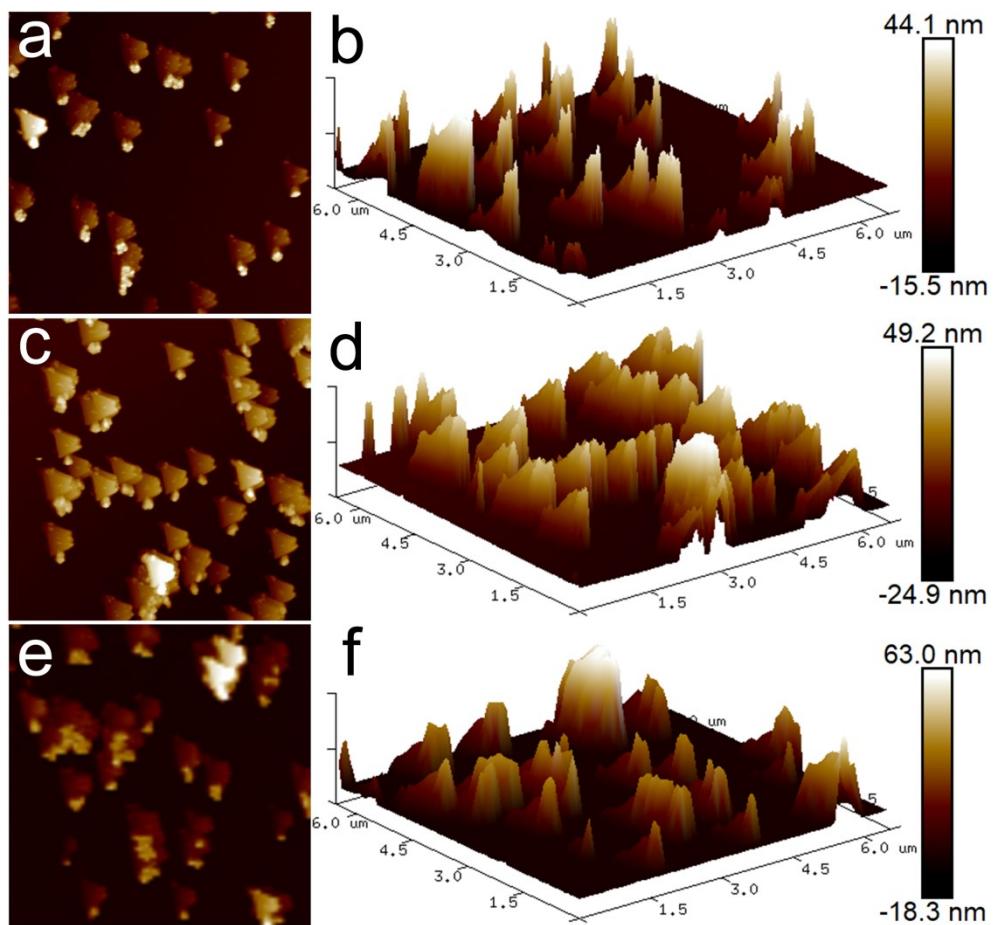
**Figure S1.** (a) Schematic setup and boundary absorption conditions used for the simulation of electromagnetic field around the BLAuNA2/ZnO heterostructure. (b) BLAuNAs model with a height of 60 nm used for the FDTD simulation.



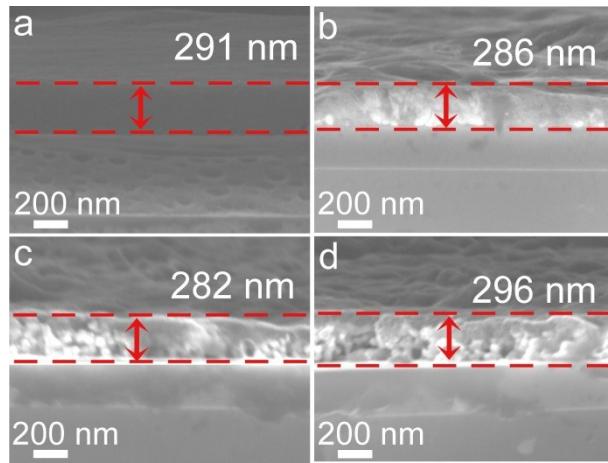
**Figure S2.** SEM images of (a) 2- and (b) 3-ML Au NP films.



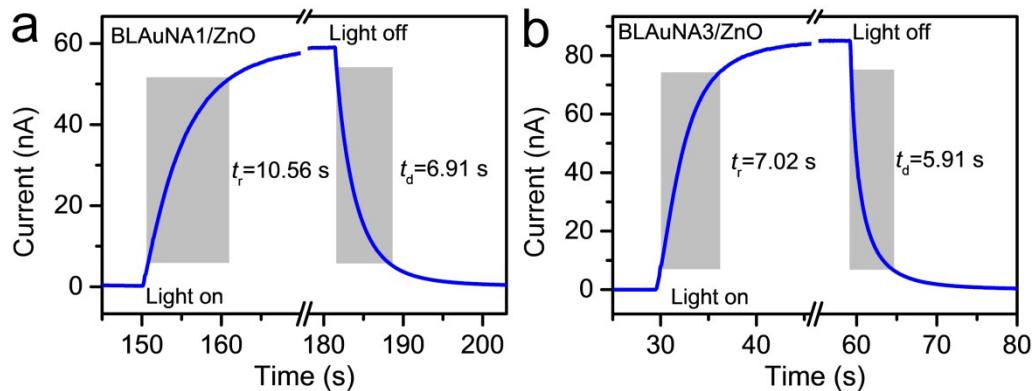
**Figure S3.** (a) Linear scan curves and (b) chronoamperometric curves for the 1-, 2-, and 3-ML Au-NP films at 0.7 V (vs. MSE) in a 0.5 M KCl solution.



**Figure S4.** (a, c, and e) top-view and (b, d, and f) side-view AFM images of the (a, b) 1-, (c, d) 2-, and (e, f) 3-ML AuNP films after electrochemical treatment at 0.7 V (vs. MSE) in 0.5 M KCl solution for 120 s.



**Figure S5.** Cross-sectional SEM images of (a) pristine ZnO QDs film, (b) BLAuNA1/ZnO heterostructure, (c) BLAuNA2/ZnO heterostructure, and (d) BLAuNA3/ZnO heterostructure.



**Figure S6.** Rise/decay time of (a) the BLAuNA1/ZnO heterostructures photodetector and (b) the BLAuNA3/ZnO heterostructures photodetector under the illumination of the 365 nm light ( $16.9 \text{ mW/cm}^2$ ) at a bias voltage of 5 V.

**Table S1.** Comparison of the performance of the current BL-AuNA2/ZnO heterostructures photodetector and other photodetectors made from semiconductor materials combined with plasmonic nanostructures.

Materials	Light source (nm)	Bias (V)	R (mA/W)	$t_r$ (s)	$t_d$ (s)	EQE (%)
p-ZnO–Au <sup>1</sup>	245	5	–	24	15	–
Au NPs/CdMoO <sub>4</sub> microplates/ZnO film <sup>2</sup>	350	5	321.1	16	9.2	–
ZnO/Au nanoantennas <sup>3</sup>	365	10	231.4	3.55	1.49	78.8
Au–NPs/MoO <sub>3</sub> /Si <sup>4</sup>	420	1	0.0035	0.035	0.038	–
Au NPs/IZO PD <sup>5</sup>	410 515	1	~100 ~0.2	–	–	–
Au-ZnO nanocomposite <sup>6</sup>	UV 550	5	~60 ~0.37	–	–	–
Au NPs/p-ZnO NSs/n-ZnO <sup>7</sup>	365 520	1	25.4 0.58	~70 –	~150 –	~8.7 –
Au NPs/TiO <sub>2</sub> /ZnO:Y NWs <sup>8</sup>	365 525	1	14.8 ~1	<1 ~94	~30 ~187	5.1 –
BL-AuNA2/ZnO heterostructures (this work)	365 532	5	61.4 ~0.05	8.9 6.5	8.4 20	21.8 11.3

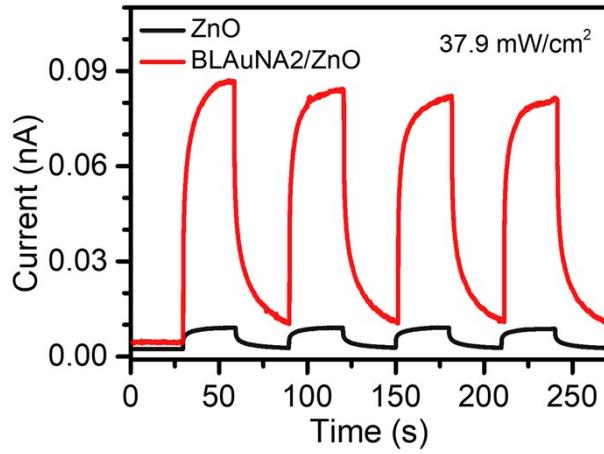


Figure S7.  $I-t$  response of the pure ZnO QDs photodetector and the optimal BLAuNA2/ZnO heterostructure photodetector at a bias voltage of 5 V and under intermittent 532 nm light illumination ( $37.9 \text{ mW/cm}^2$ ).

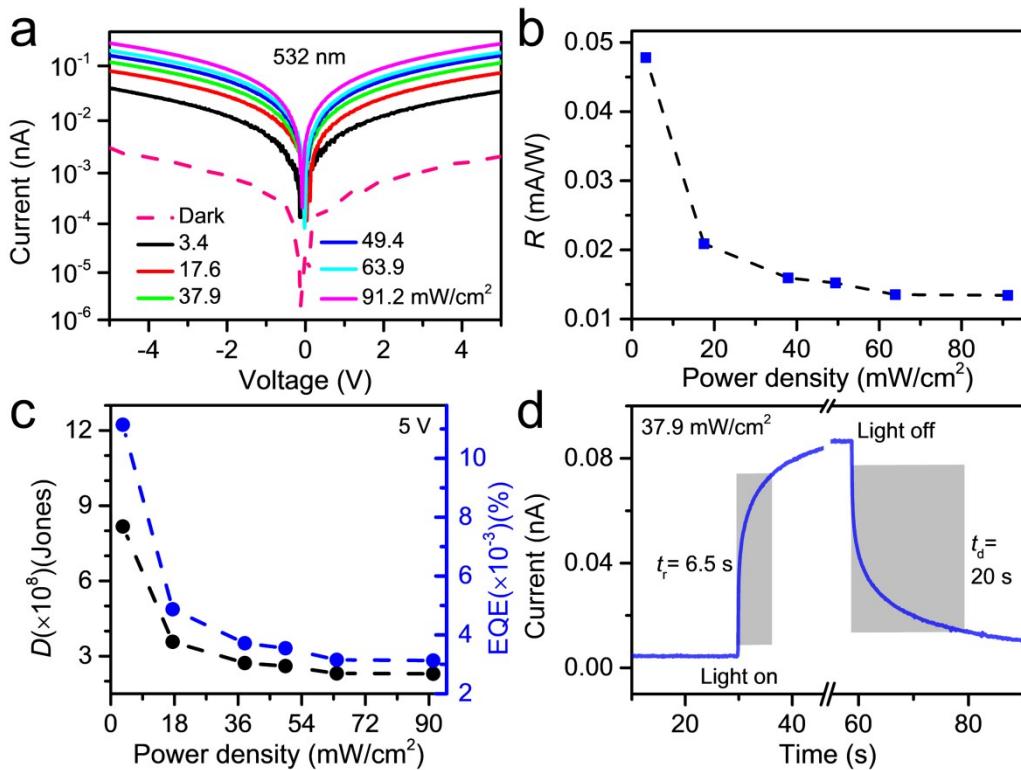


Figure S8. (a)  $I-V$  curves of the BLAuNA2/ZnO heterostructures photodetector in dark conditions and under 532 nm light illumination at different power densities. (b)  $R$  and (c)  $D$  and EQE versus light power density at a bias voltage of 5 V. (d) Rise/decay time of the photodetector measured at a power density of 37.9  $\text{mW/cm}^2$ .

## References

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